

Quantum Hall and Insulating States of a Broken-gap 2-D Electron-hole System

K. Takashina¹, R.J. Nicholas¹, C. Petchsingh¹,
N. Mason¹,

D.K. Maude², J.C. Portal²

¹University of Oxford, UK

²LMCI-CNRS, Grenoble, France

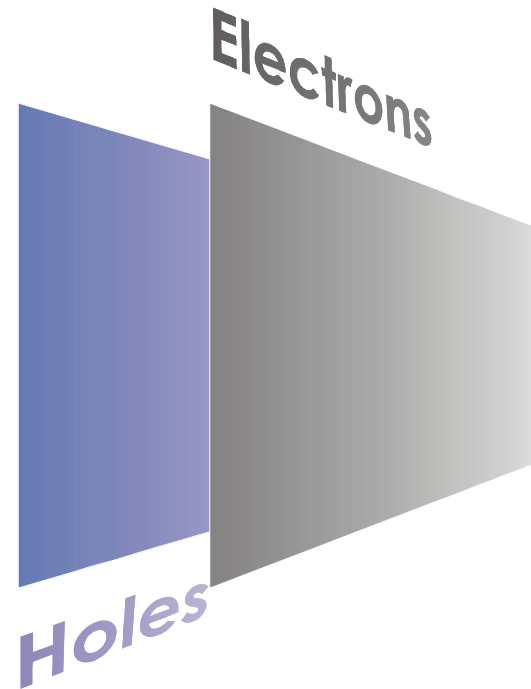
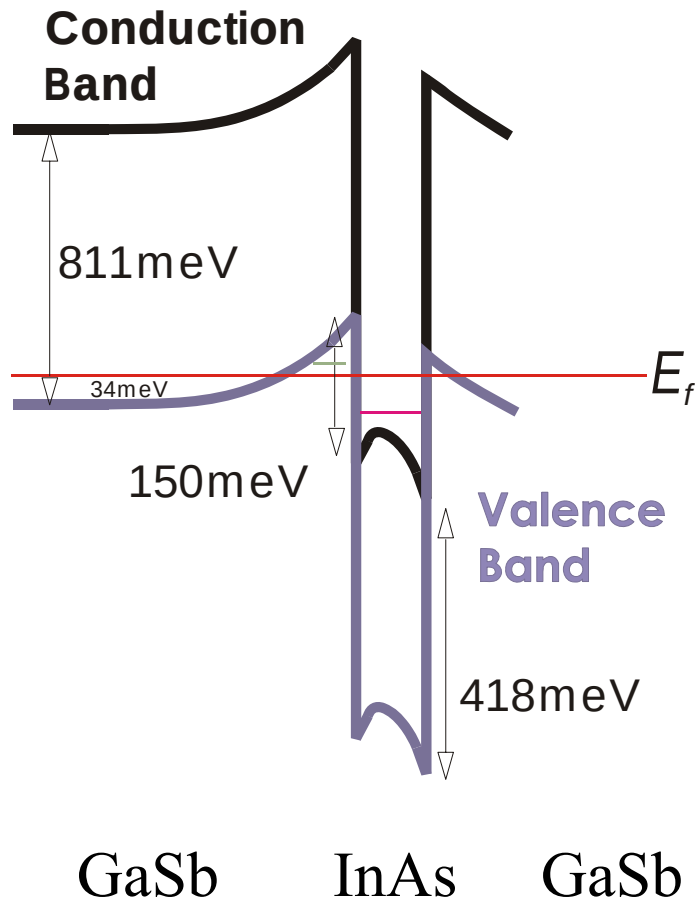
EU & EPSRC of UK



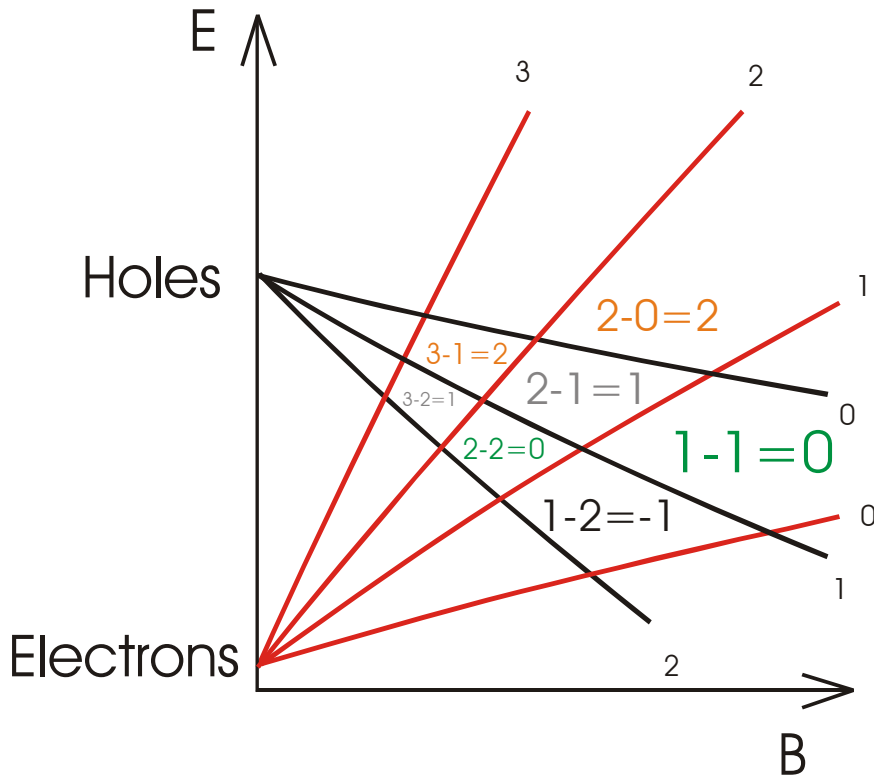
Talk Outline

- Insulating states $\sigma_{xx} = 0; \sigma_{xy}^{\text{net}} = \sigma_{xy}^{\text{e}} + \sigma_{xy}^{\text{h}} = 0$
 - Novel behaviour
 - Edge-channel conduction [Physica B 298 28 (2001)]
 - Magnetoconductance fluctuations
 - In-plane magnetic field
- Quantum Hall states $\sigma_{xx} = 0; \sigma_{xy}^{\text{net}} = \sigma_{xy}^{\text{e}} + \sigma_{xy}^{\text{h}} \neq 0$
 - Breakdown and current dependence [Physica B 298 8 (2001)]
 - Width dependence

InAs/GaSb Broken Gap System



Landau levels in magnetic field



- Electron states
- Hole states

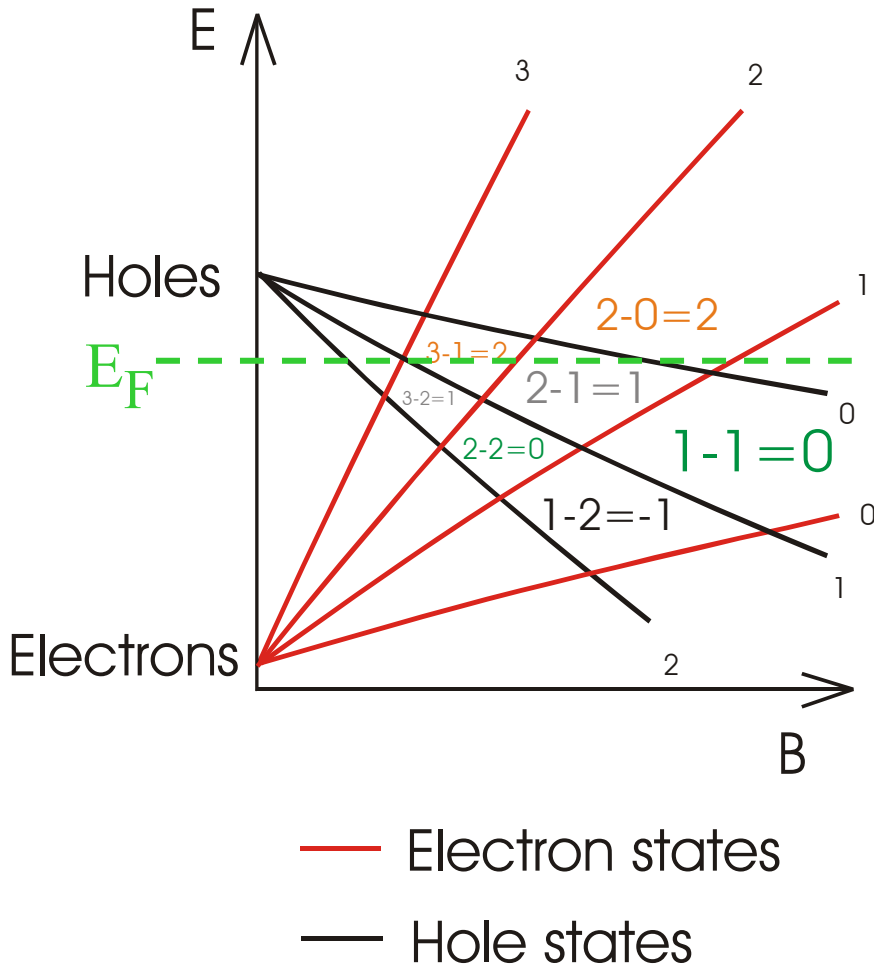
Behaviour of quantized Hall conductance:

$$R_H = -h/e^2(\nu_e - \nu_h)$$

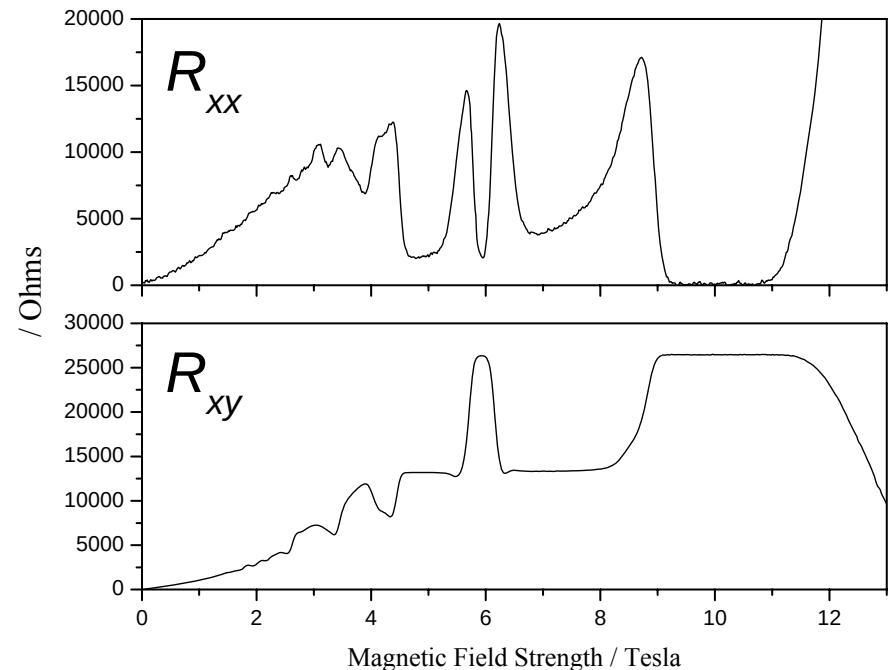
consistent with $\sigma_{\text{net}} = \sigma_e + \sigma_h$

[Mendez et al., PRL 55 2216 (1985)]

Landau levels in magnetic field

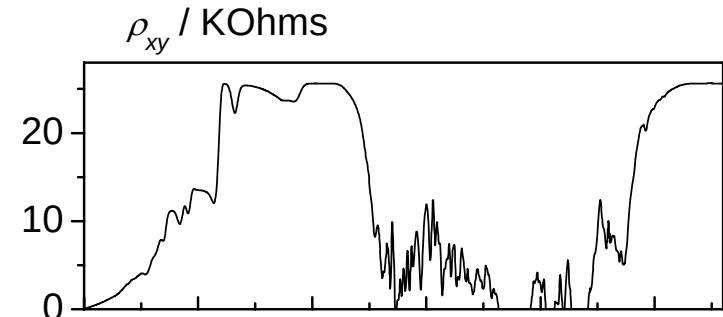
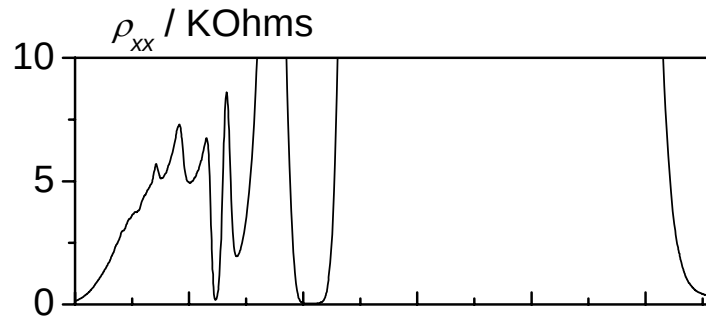


Compensated Quantum Hall Effect

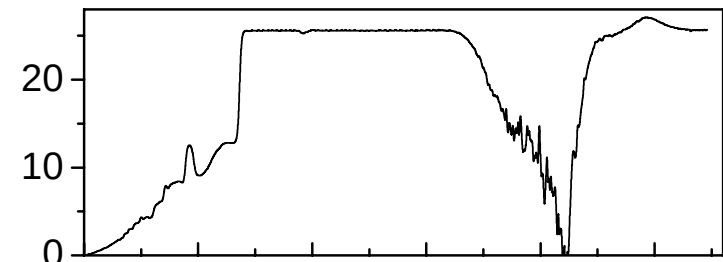
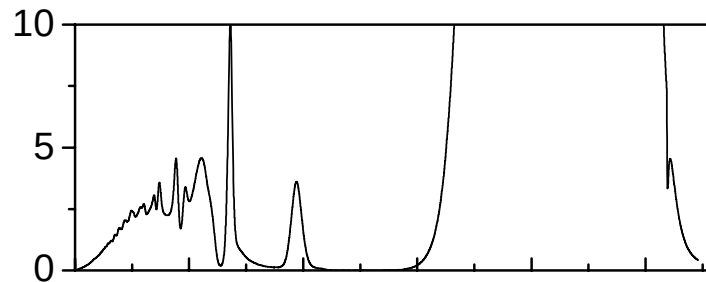


Insulating state forms with increased n_h

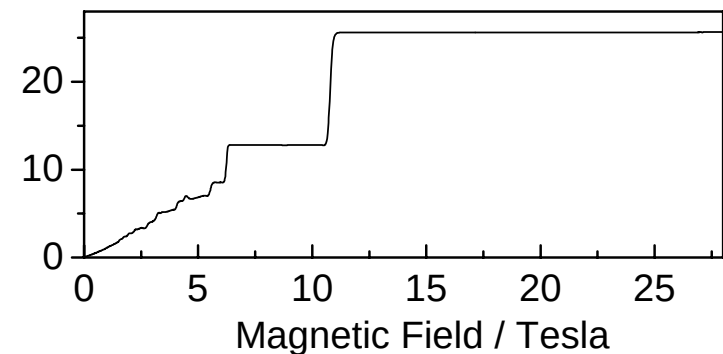
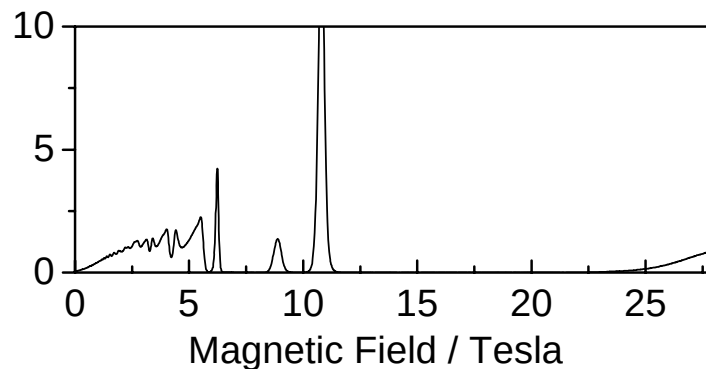
$n_e = 7.9$,
 $n_h = 6.1 \times 10^{11} \text{cm}^{-2}$



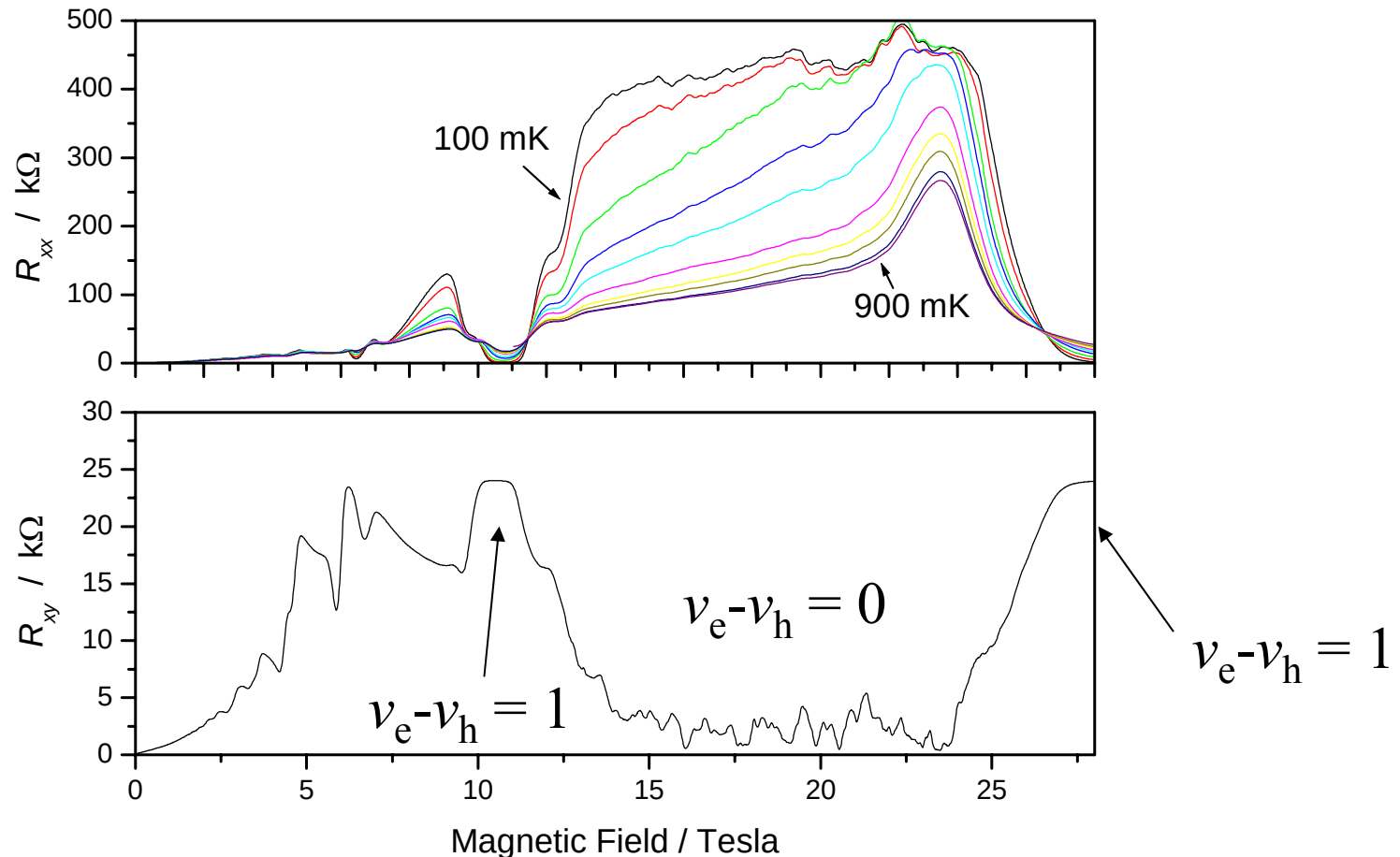
$n_e = 8.0$,
 $n_h = 5.2 \times 10^{11} \text{cm}^{-2}$



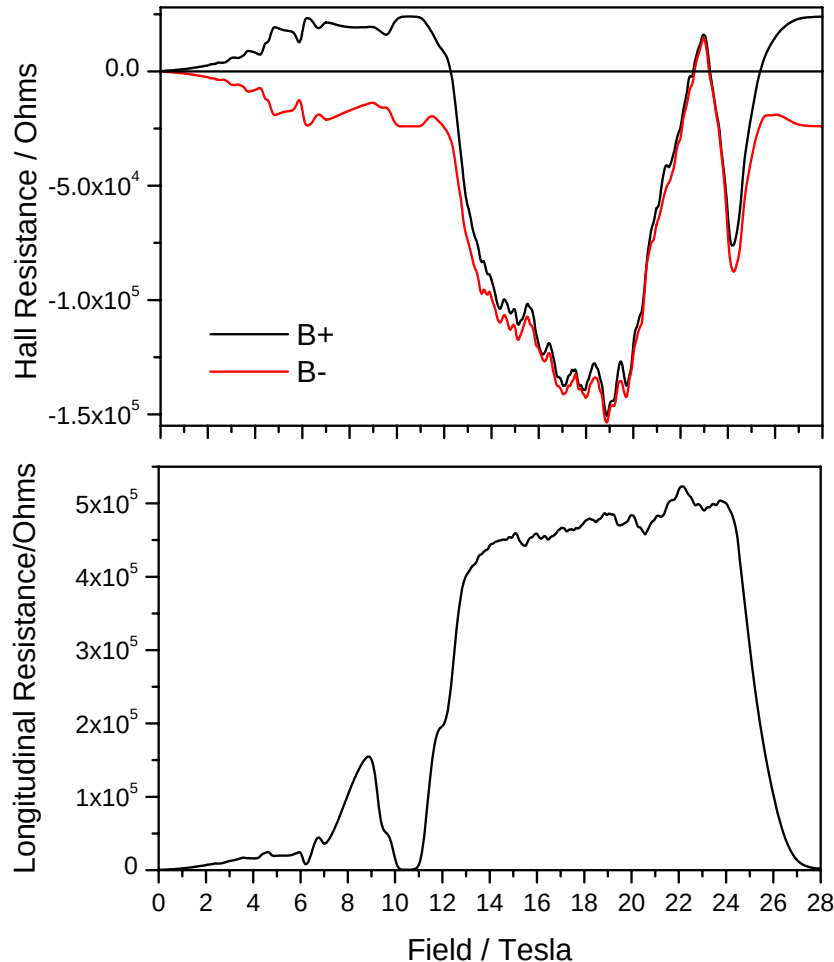
$n_e = 7.8$,
 $n_h = 3.7 \times 10^{11} \text{cm}^{-2}$



ρ_{xx} oscillates between ‘metallic’ and
‘insulating’ behaviour

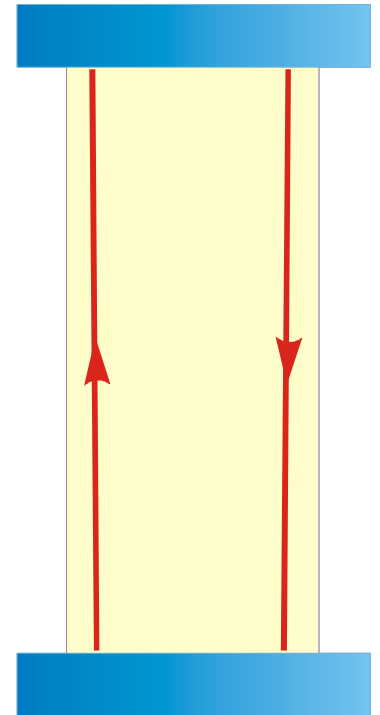
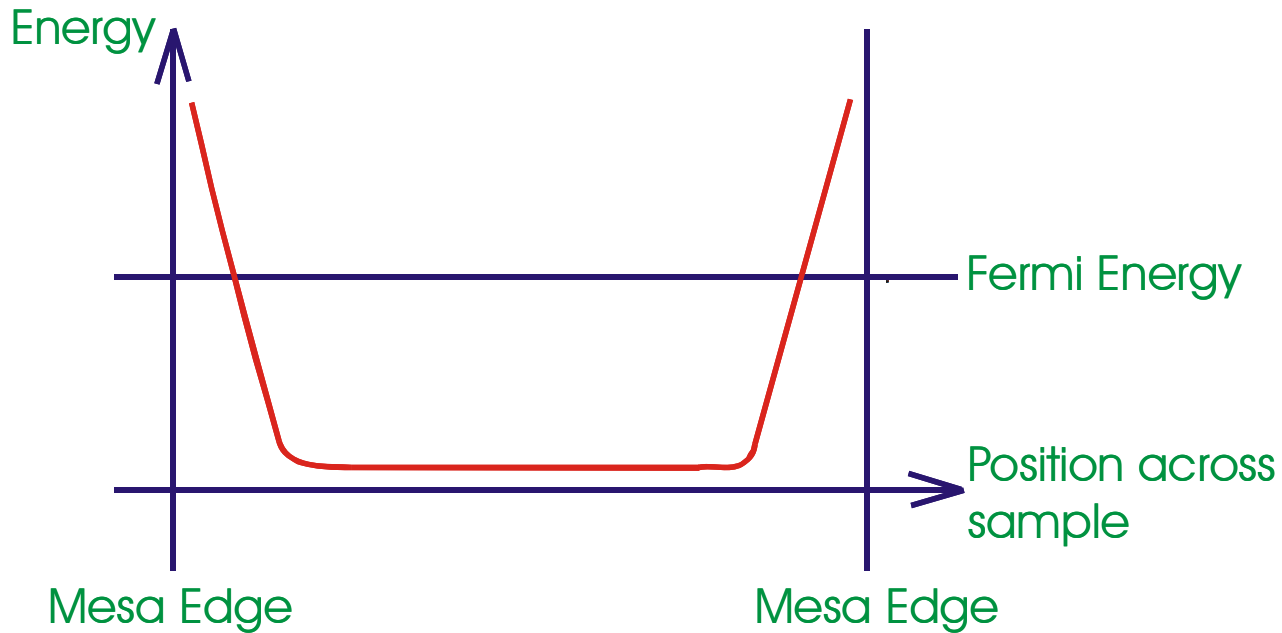


Insulating state: $\nu_e - \nu_h = 0$

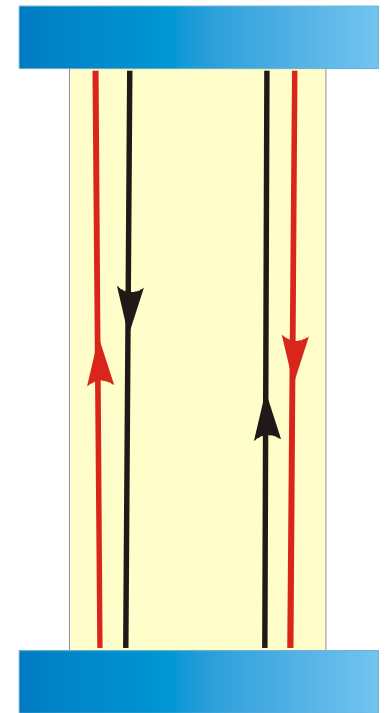
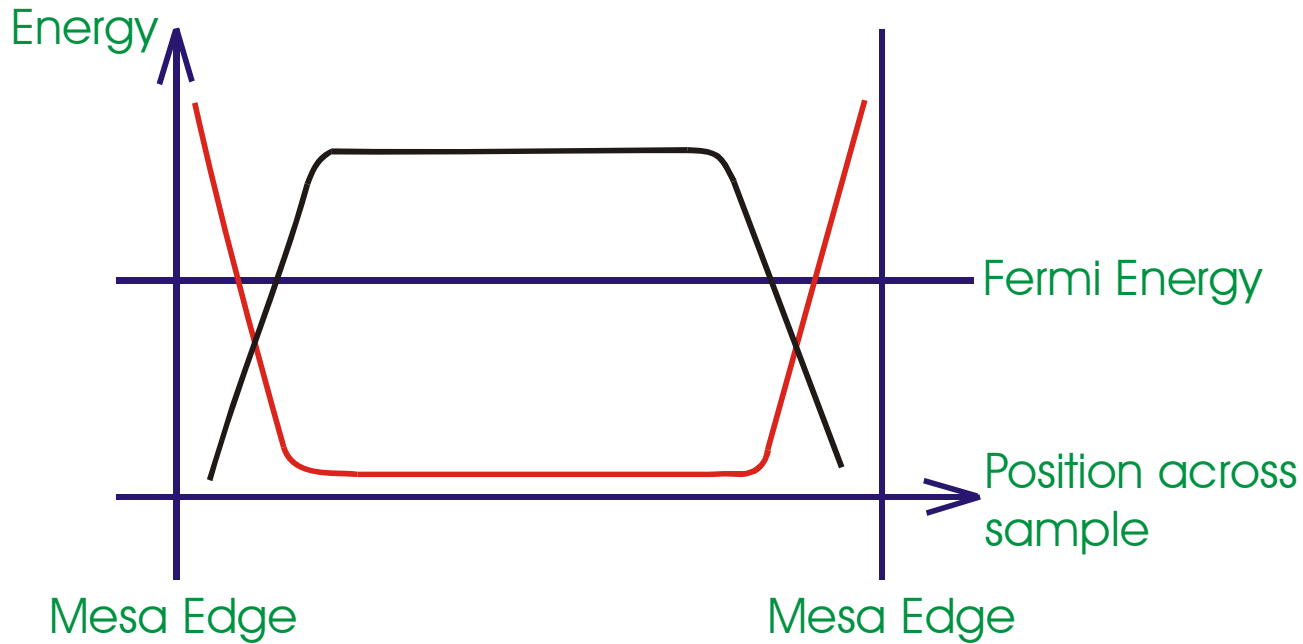


- The Hall resistance becomes **symmetric** under **field reversal**.
- Values larger than 50% of ρ_{xx} ($R_{xx}/\text{sq.}$).
- No functional relation with R_{xx} .
- **Reproducible fluctuations**.
- Macroscopically large samples.

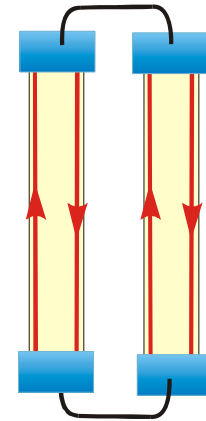
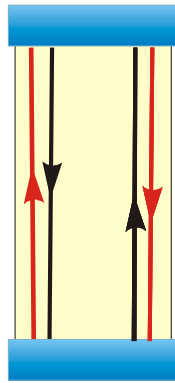
Electron edge states



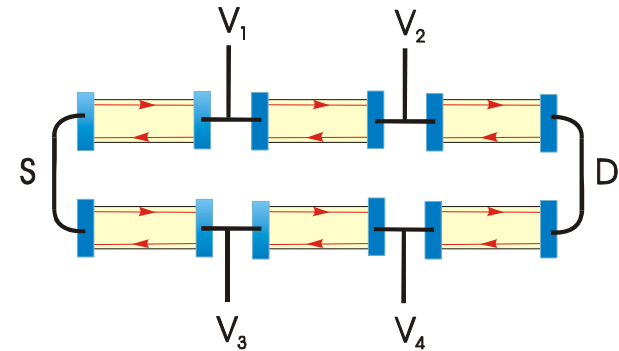
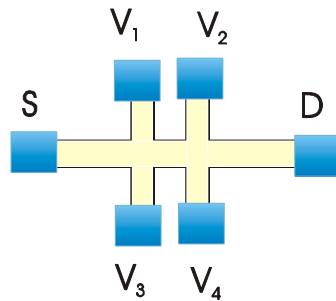
Holes: Counter-propagation



Draw system in terms
of single carrier type
 $\nu = 1$ bars.



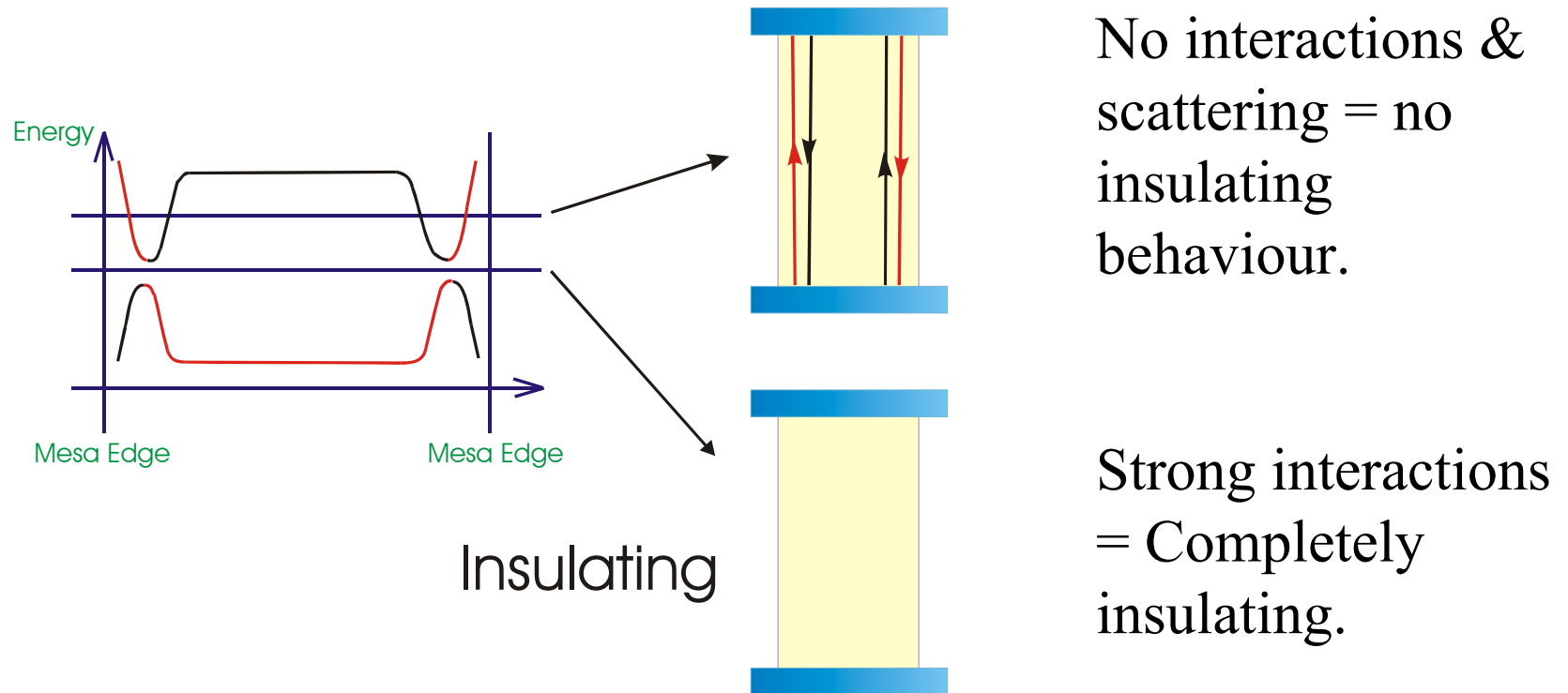
Equivalent circuit
for Hall bar:



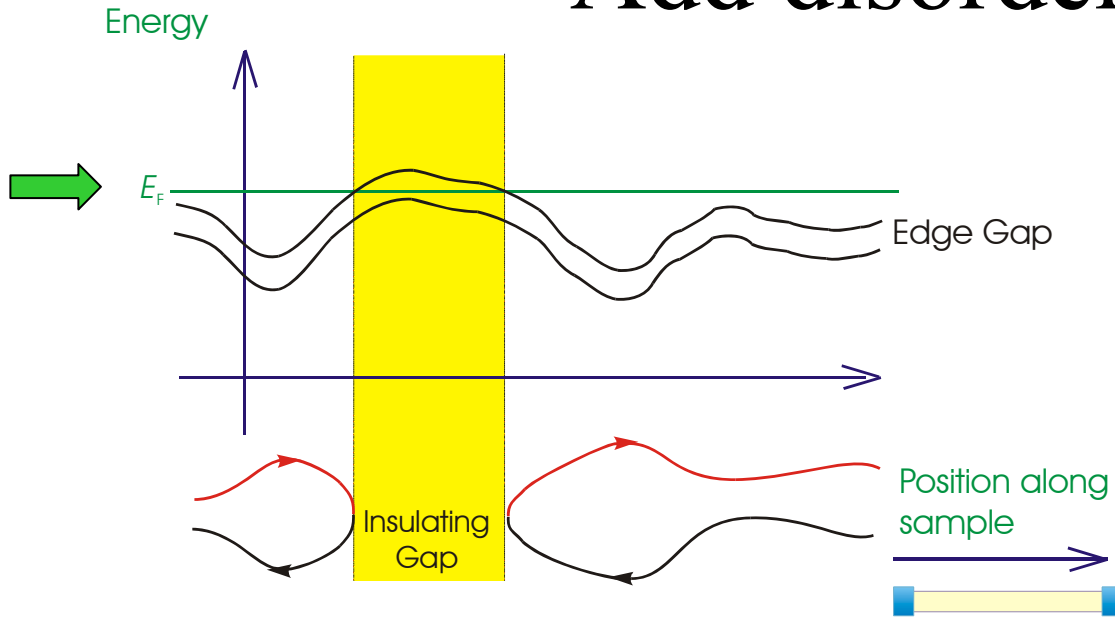
A measured longitudinal resistance would give

$$R_{xx} = (V_1 - V_2) / I_{SD} = h / 2e^2$$

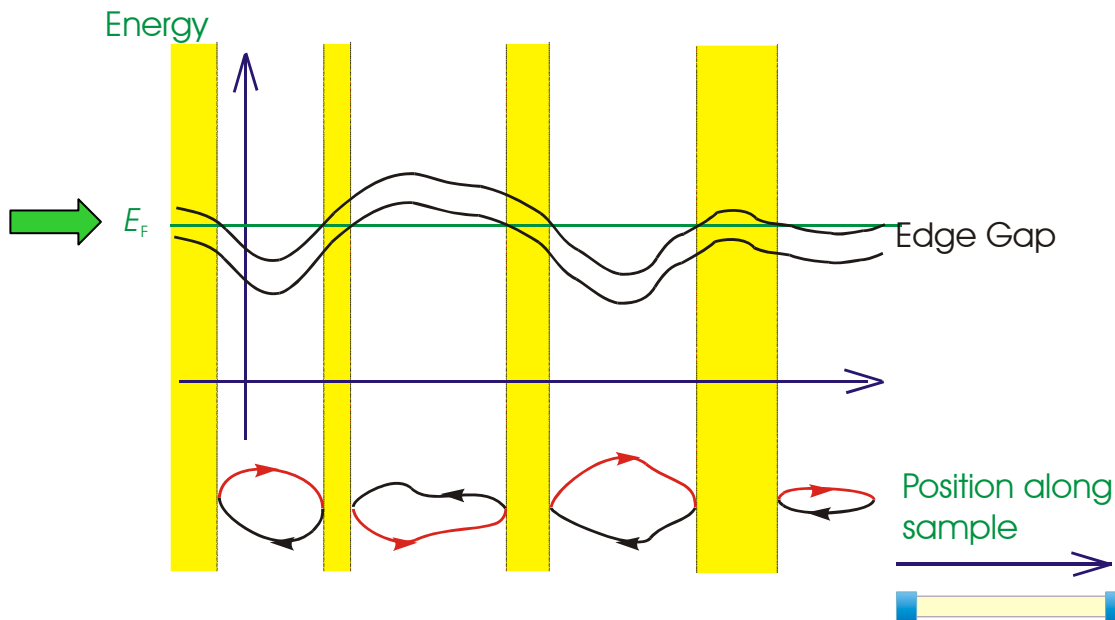
Interactions and Anticrossing



Add disorder

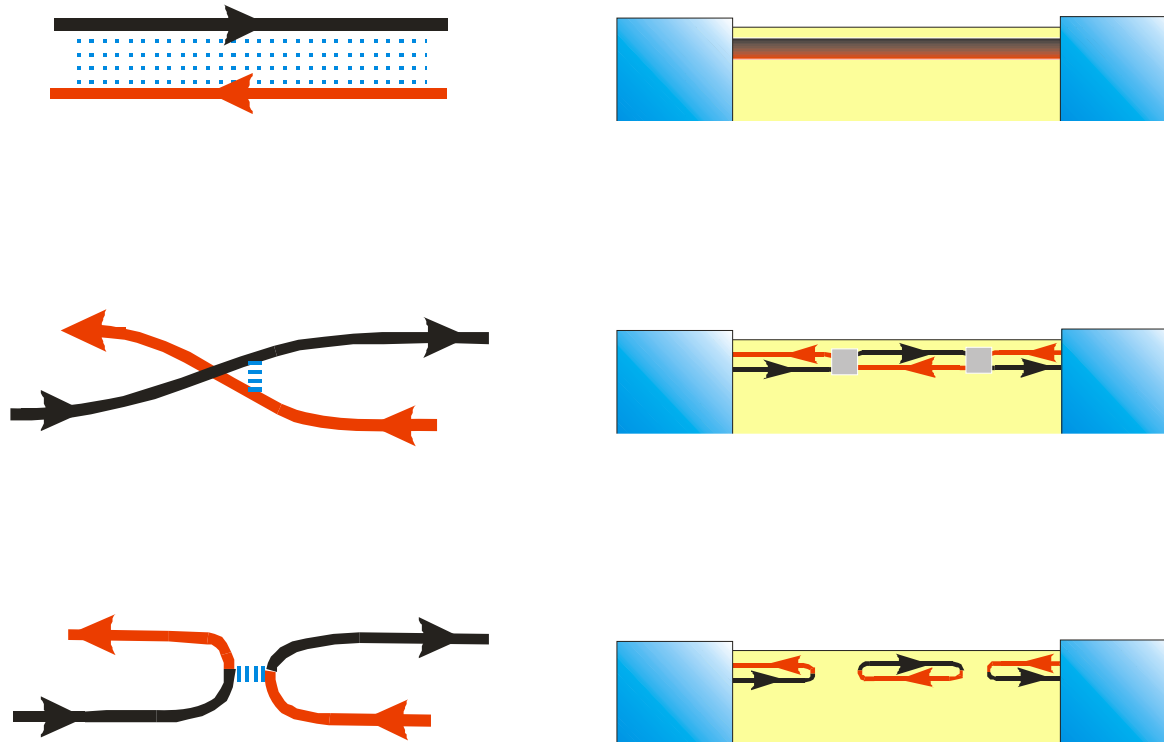


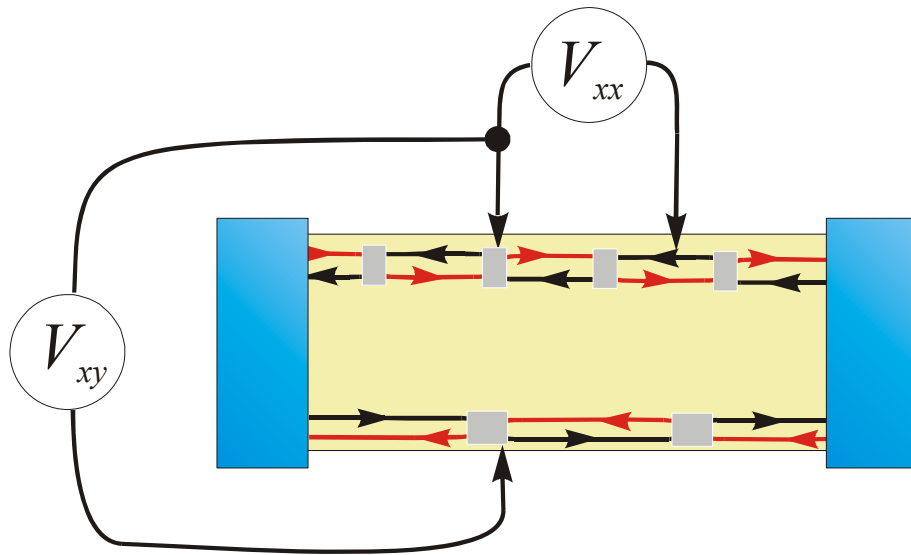
- Gaps may form where E_F cuts the gap.
- Changing the magnetic field moves the gap in energy.



- The Fermi energy cuts the gap at different positions in space.

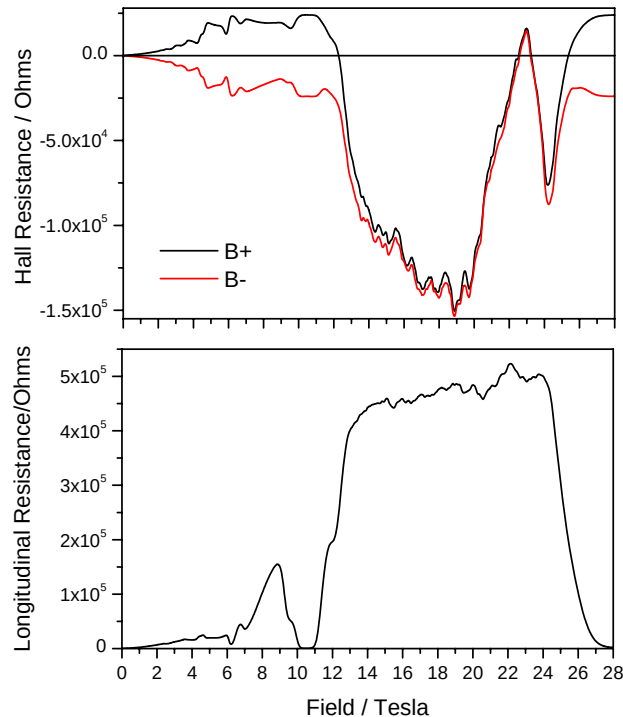
Conduction depends on strength of interactions and disorder





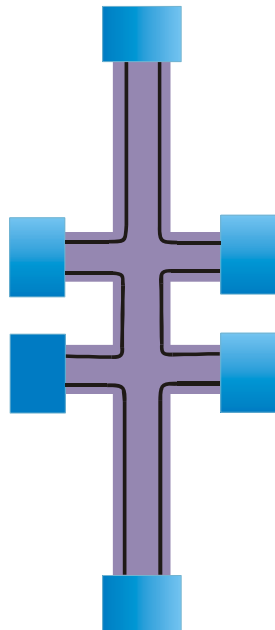
Global Picture

- Potential dropped **between** sections.
- Arrangement depends on disorder and **LL energy**.
- Symmetric Hall resistance.

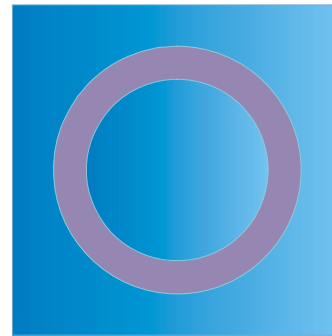


Geometry effects - No Edge State connections for Corbino Disc

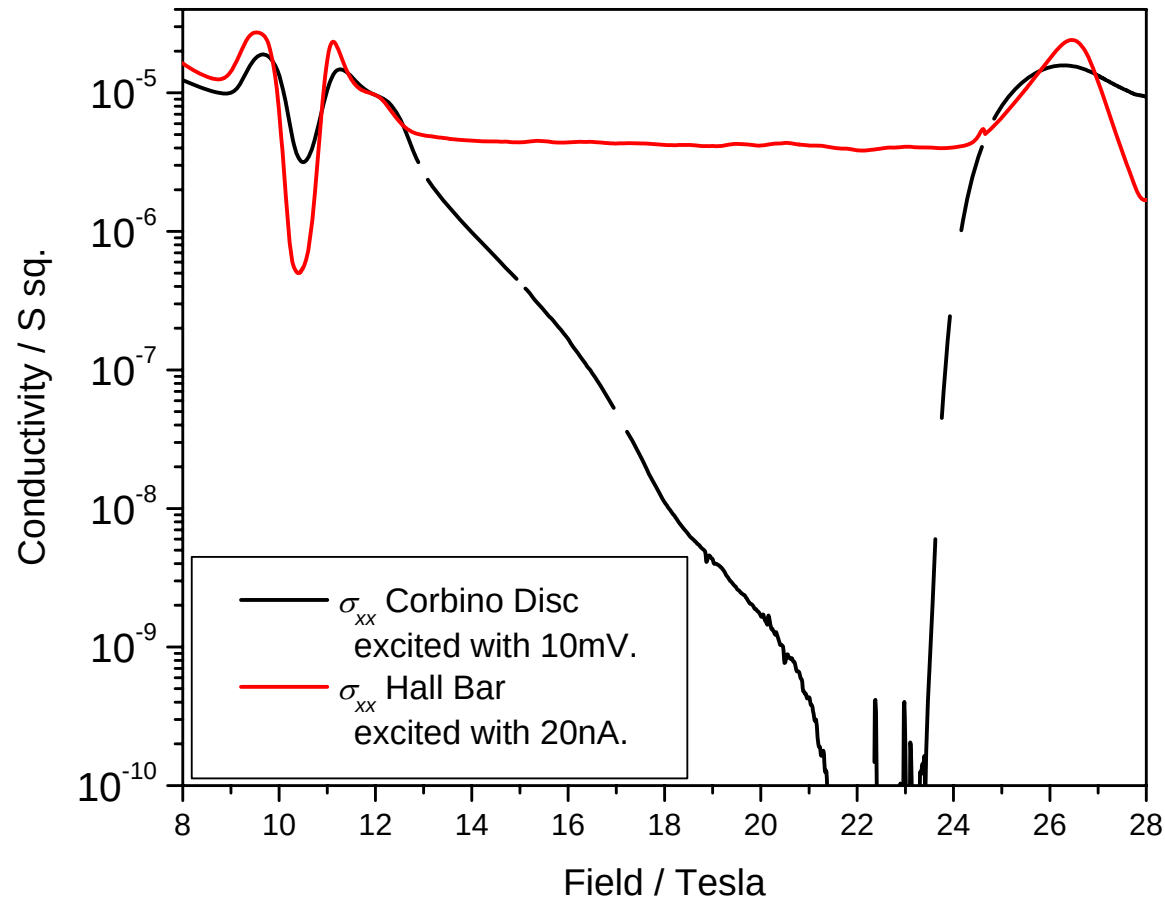
Hall Bar



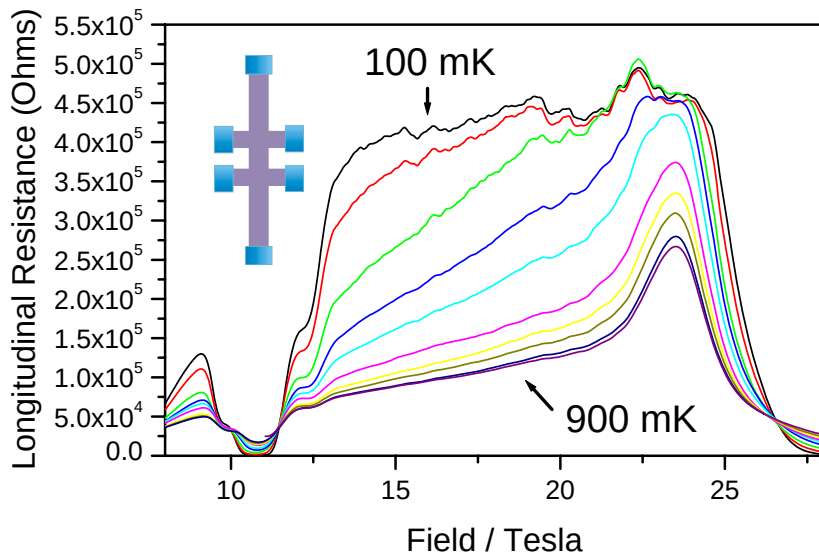
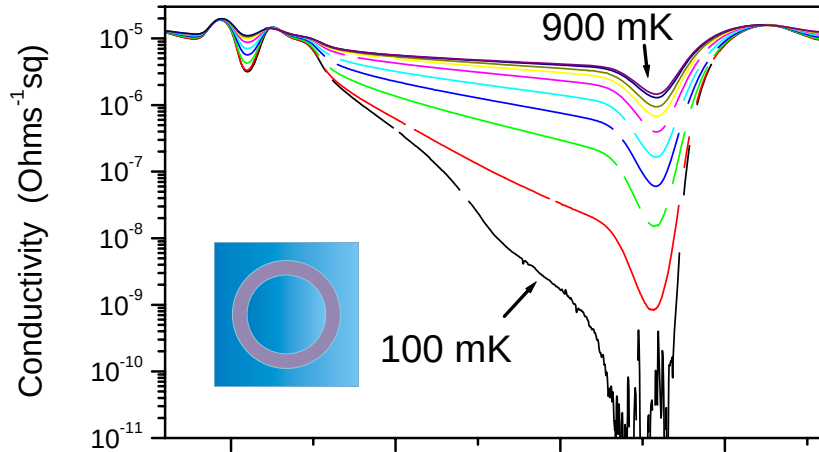
Corbino Disc



Directly Compare Conductivity



Temperature Dependence



- Hall bar resistance saturates at low temperature.
- Corbino disc continuously insulating.
- No fluctuations in Corbino disc data.
- Data reconciled with.

$$\sigma_{xx}^{Hall} = \sigma_E + g\sigma_B.$$

Edge Channel Properties

What we have shown so far:

- Edges contribute conductance with fluctuations.
- Edge-states must be drastically altered.

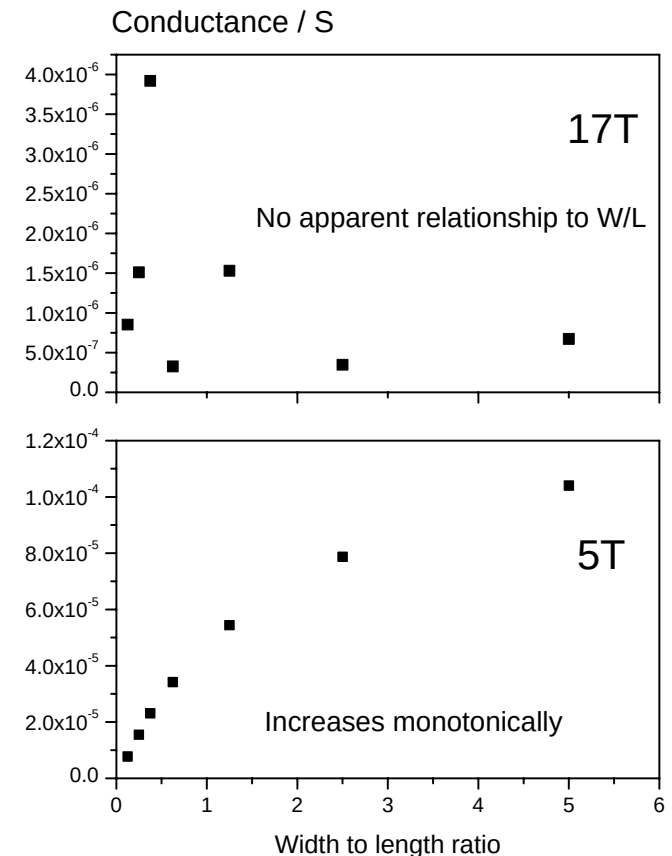
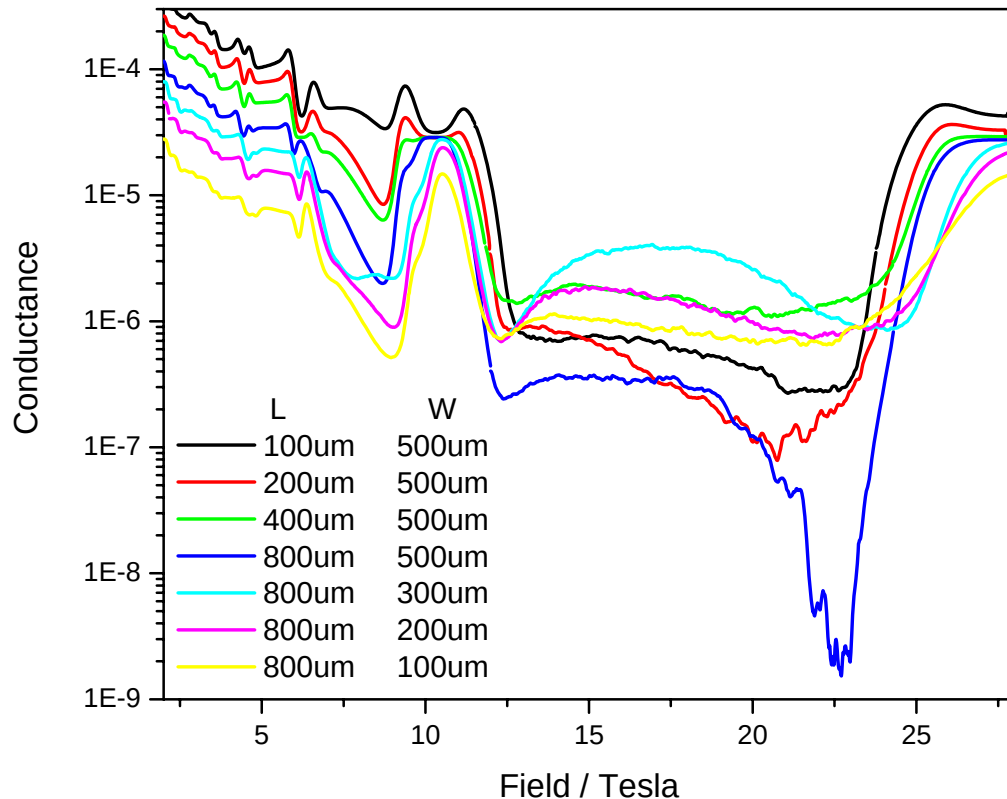
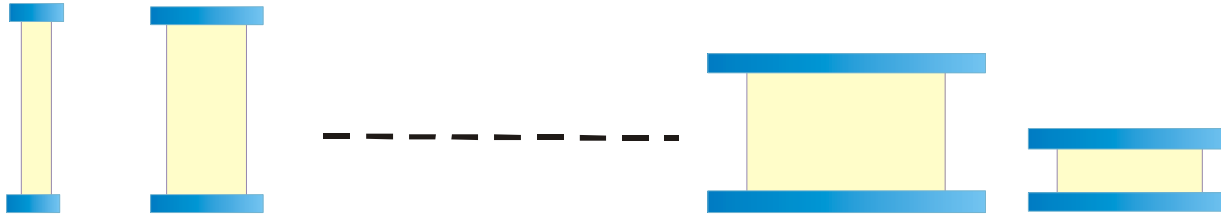
Immediate questions:

- Fluctuations – Energy or Phase effect?
- Is the conduction really affected by interactions between e and h edge states?

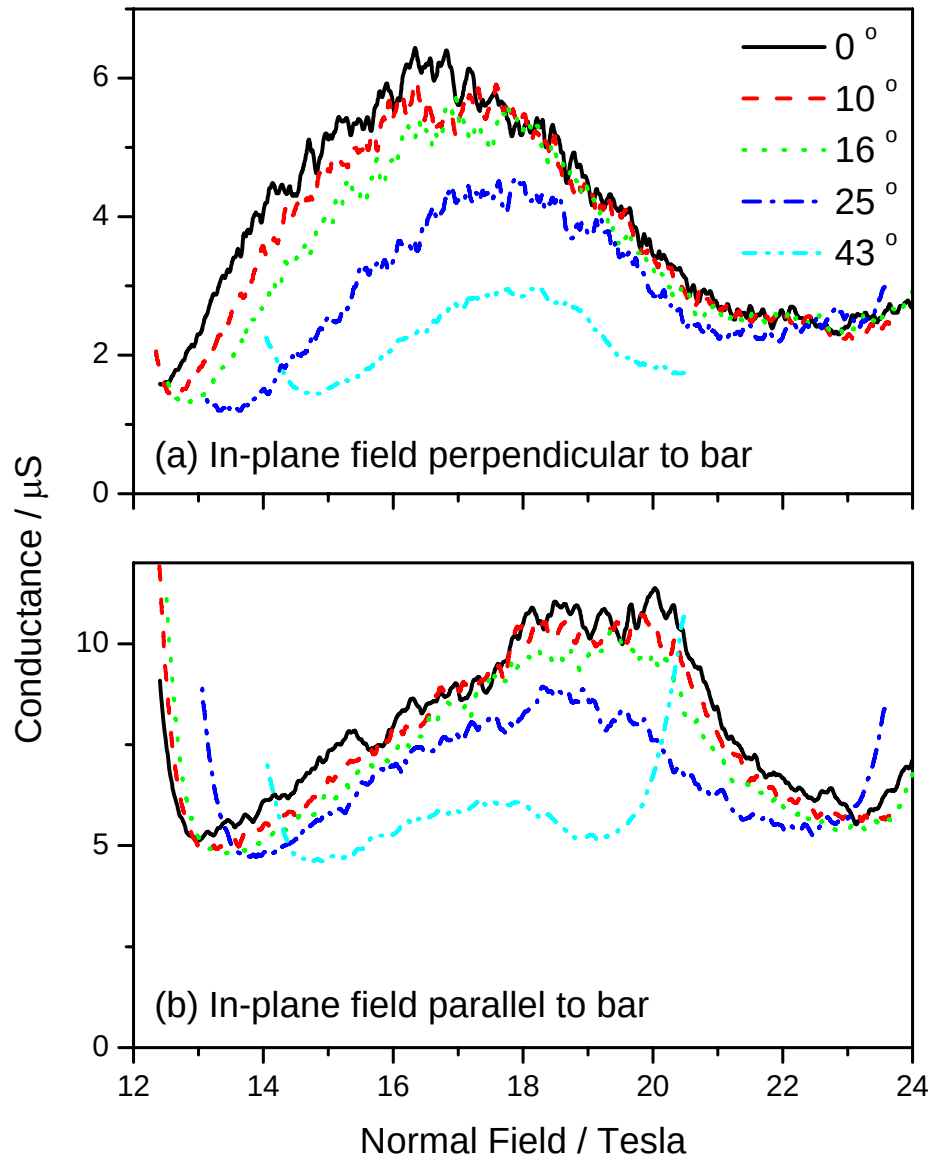
Look at dependence on:

- Width and Length
- In-plane magnetic field

2 Contact Length and Width Dependence

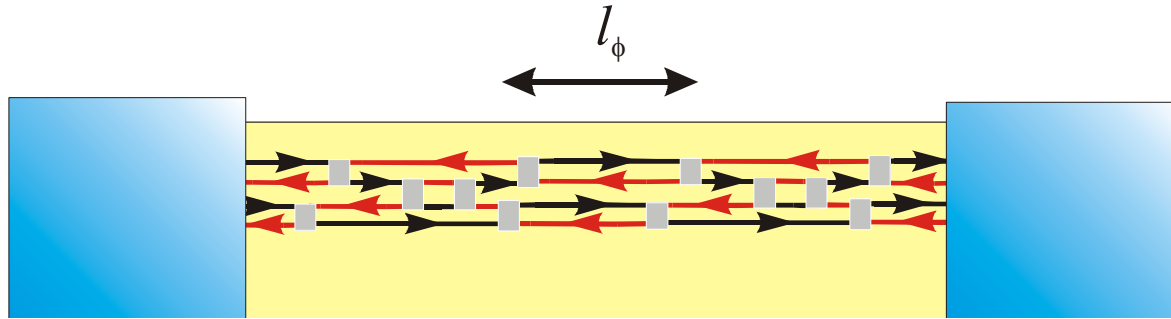


In-plane field + 2-Contact Bars



- Background changes smoothly.
- Minima at high and low field regions.
- Conductance decreases with in-plane field.
- Small fluctuations change completely from one angle to next.
- Fluctuations decreases as conductance decreases.

Universal Conductance Fluctuations

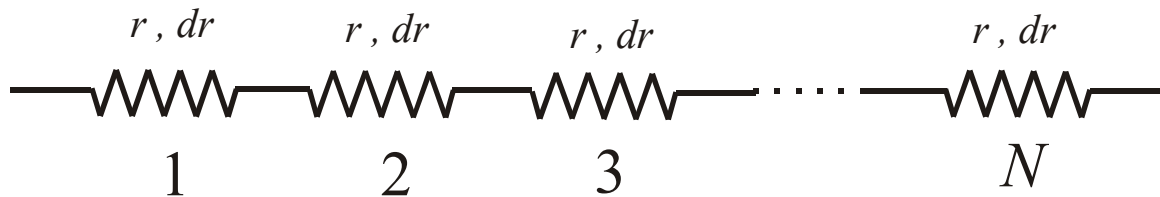


- Phase coherent sections contribute e^2/h .

Universal Magnetoconductance Fluctuations

Sections of conductance g , fluctuates by $dg (= e^2/h)$.

Add N resistors r in series. ($r = 1/g$)



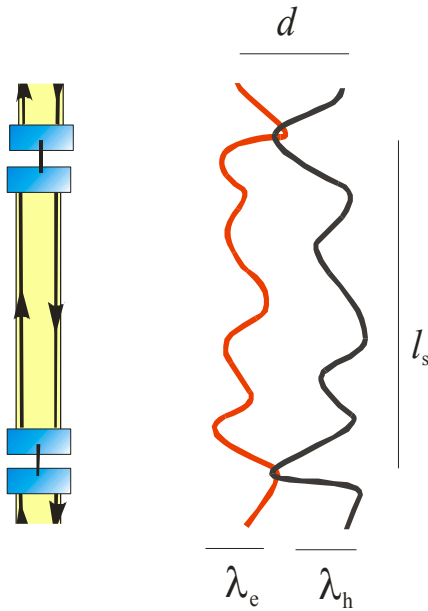
Total conductance, $G = g/N$

Total resistance, $R = Nr$, $dR = N^{1/2}dr$

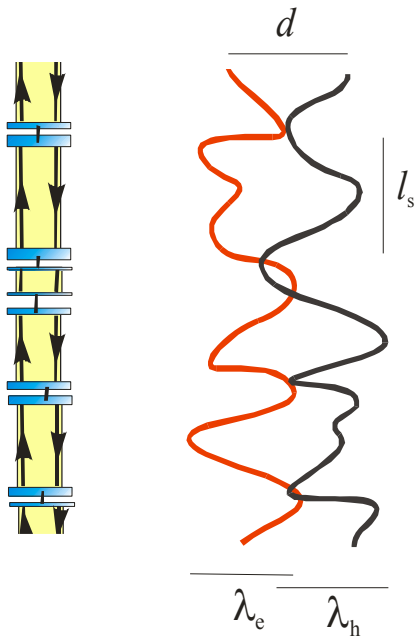
$$dG = G^2 dR = G^2 N^{1/2} (dr/dg) dg = (G/g)^{3/2} dg$$

$$dG = (G/g)^{3/2} (e^2/h)$$

No. of sections change with field

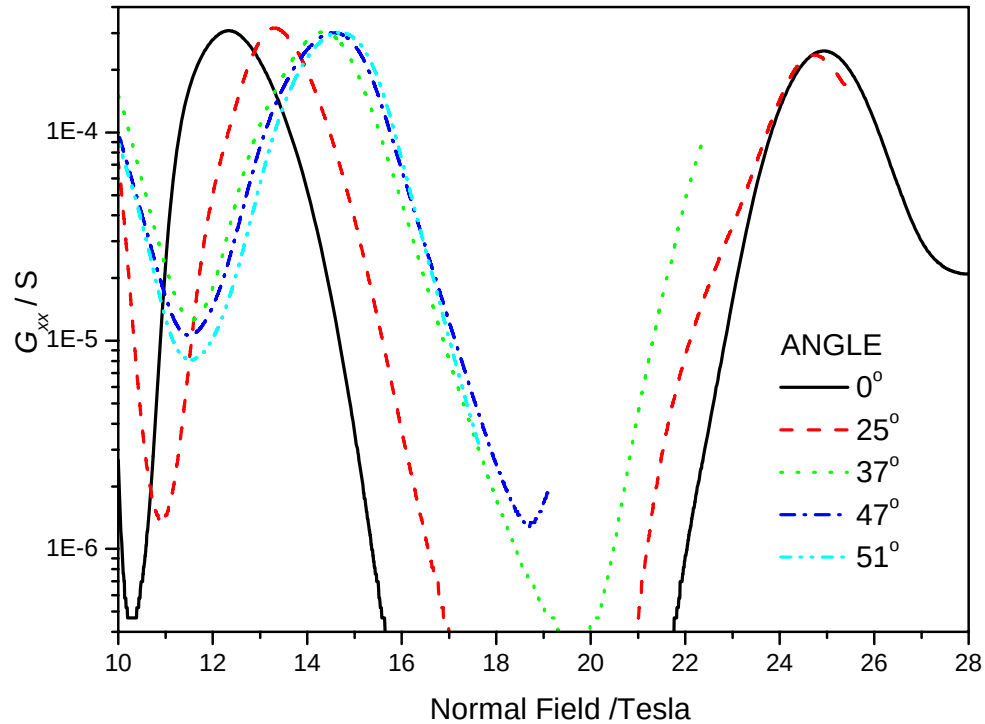
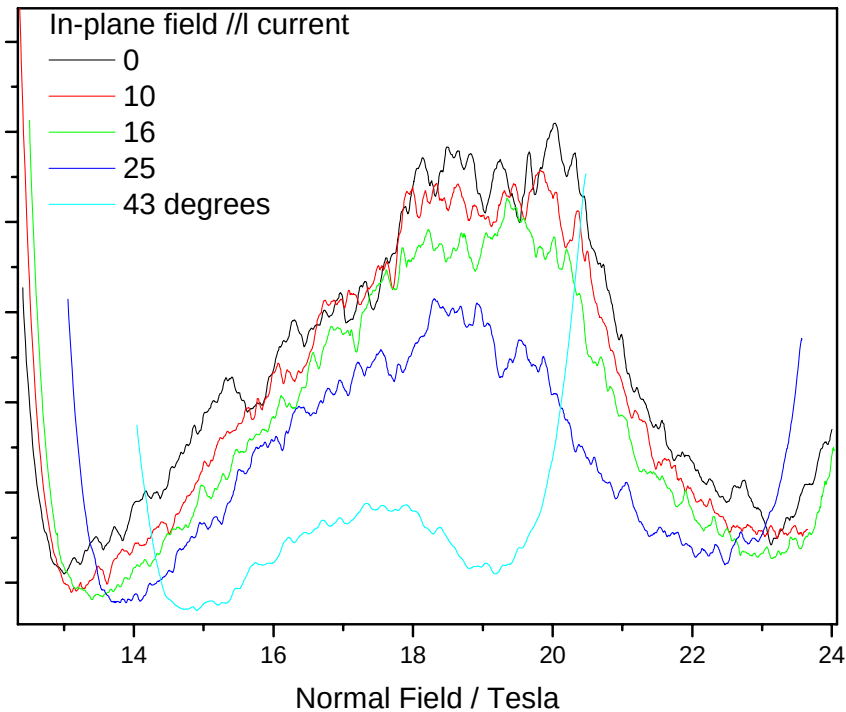


- Length of section l_s is long if localization length λ is short.



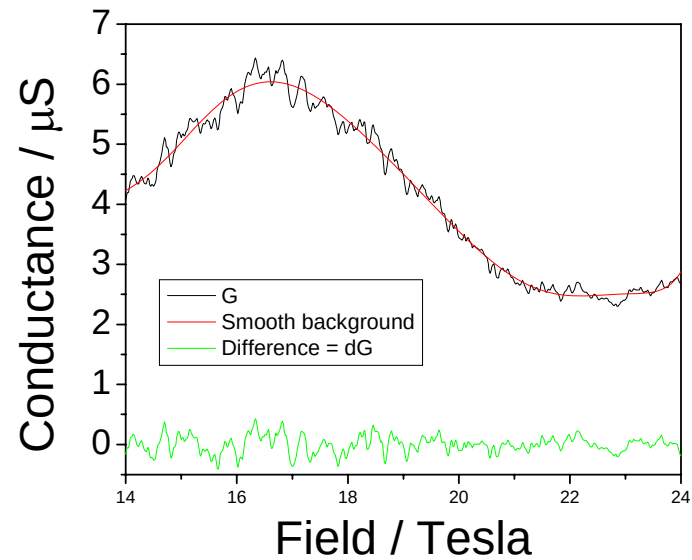
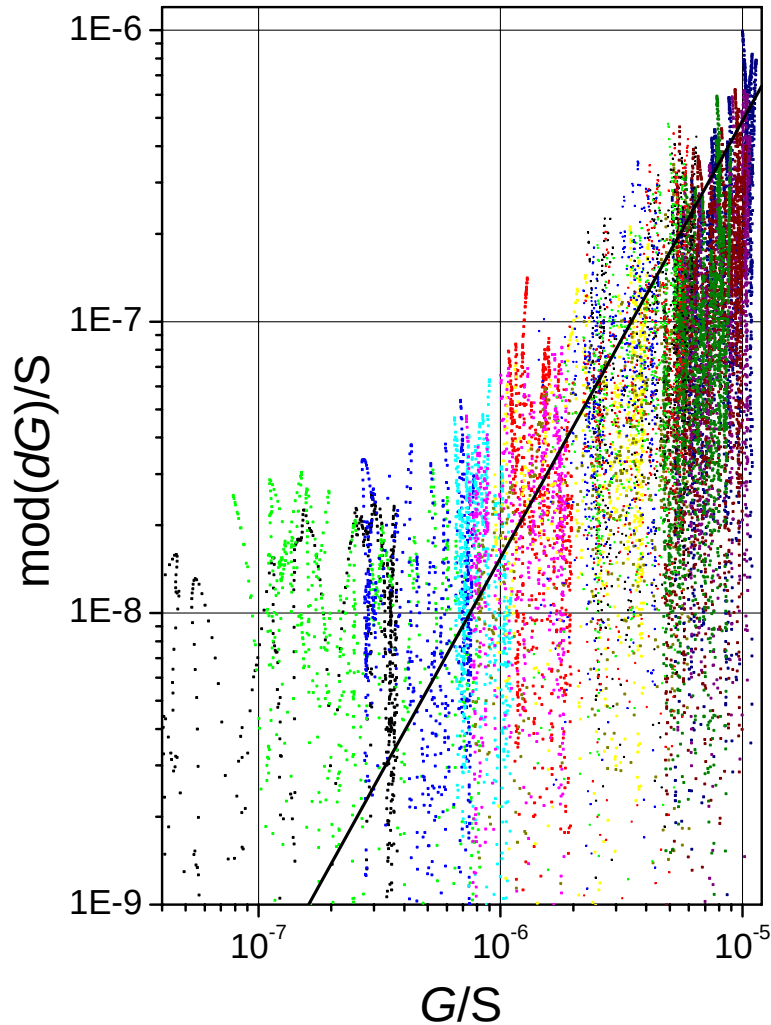
- If each section has conductance g , G decreases as λ increases.
- I.e. G^{edge} is max. when σ_{xx} min.

G^{bar} has opposite behaviour to σ_{xx}



G^{edge} decreases as localization length increases
 - more, shorter sections

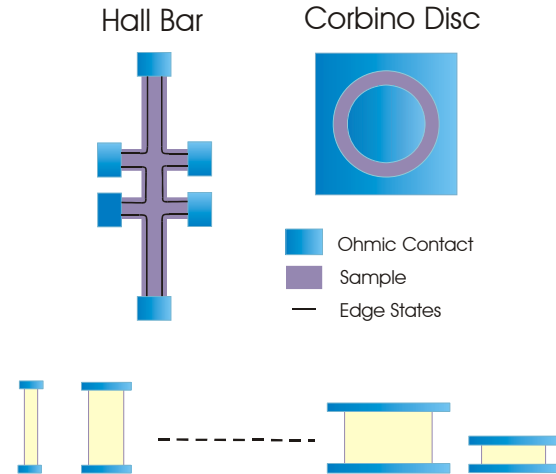
dG vs G



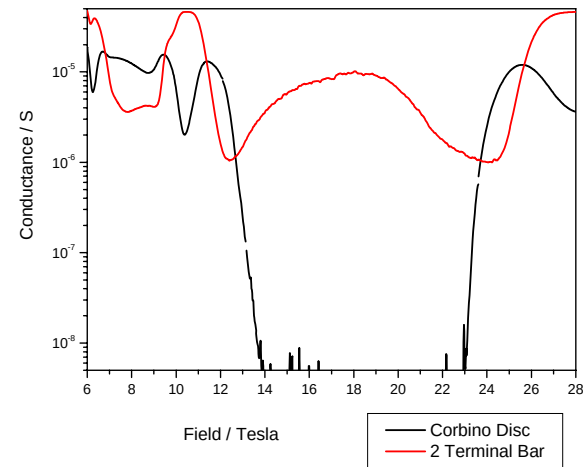
- All samples obey overall trend.
- $dG \sim G^{3/2}$ works well at large G . System well described as made up of characteristic sections of conductance g .

Summary of Insulating State

- Conduction dominated by edges.
- Fluctuations $\sim$ UCF.
- G^{edge} has opposite behaviour to σ_{xx} due to interactions between e & h edge channels.



$$dG = (G/g)^{3/2}(e^2/h)$$



Compensated Quantum Hall Effect

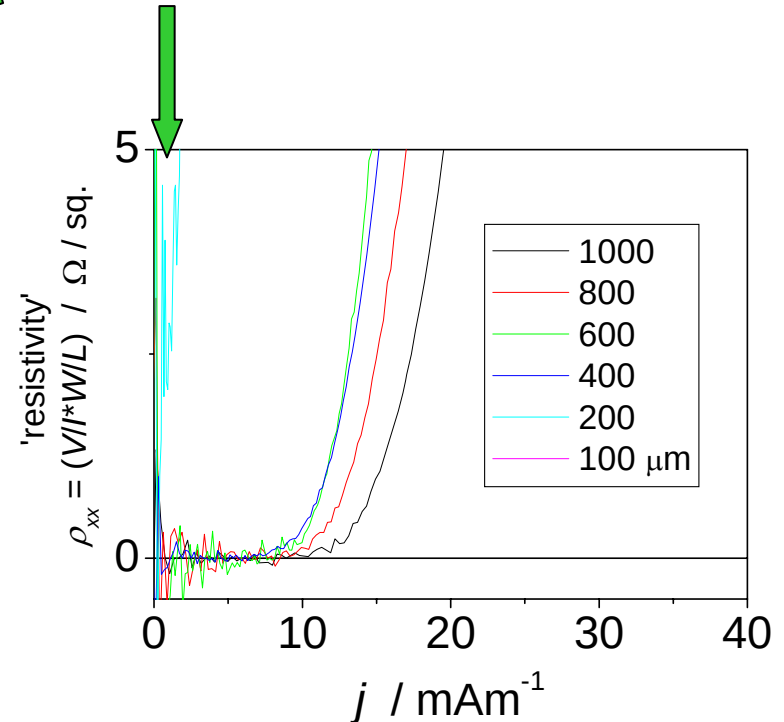
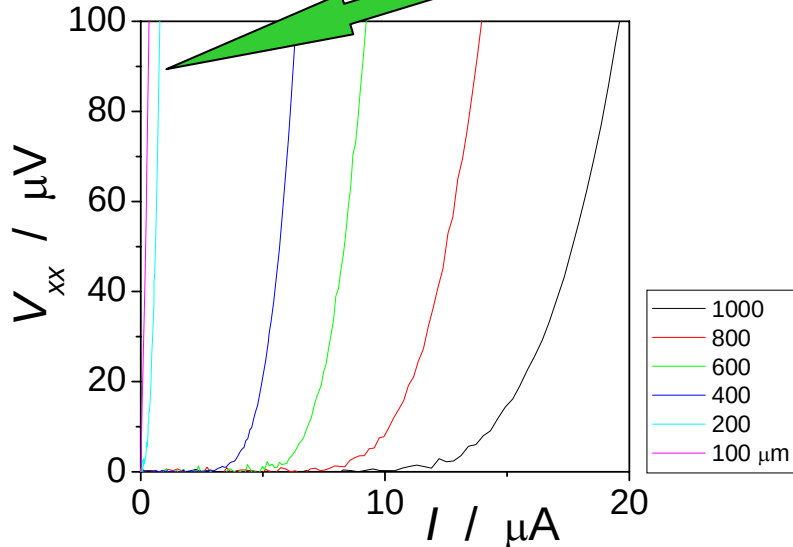
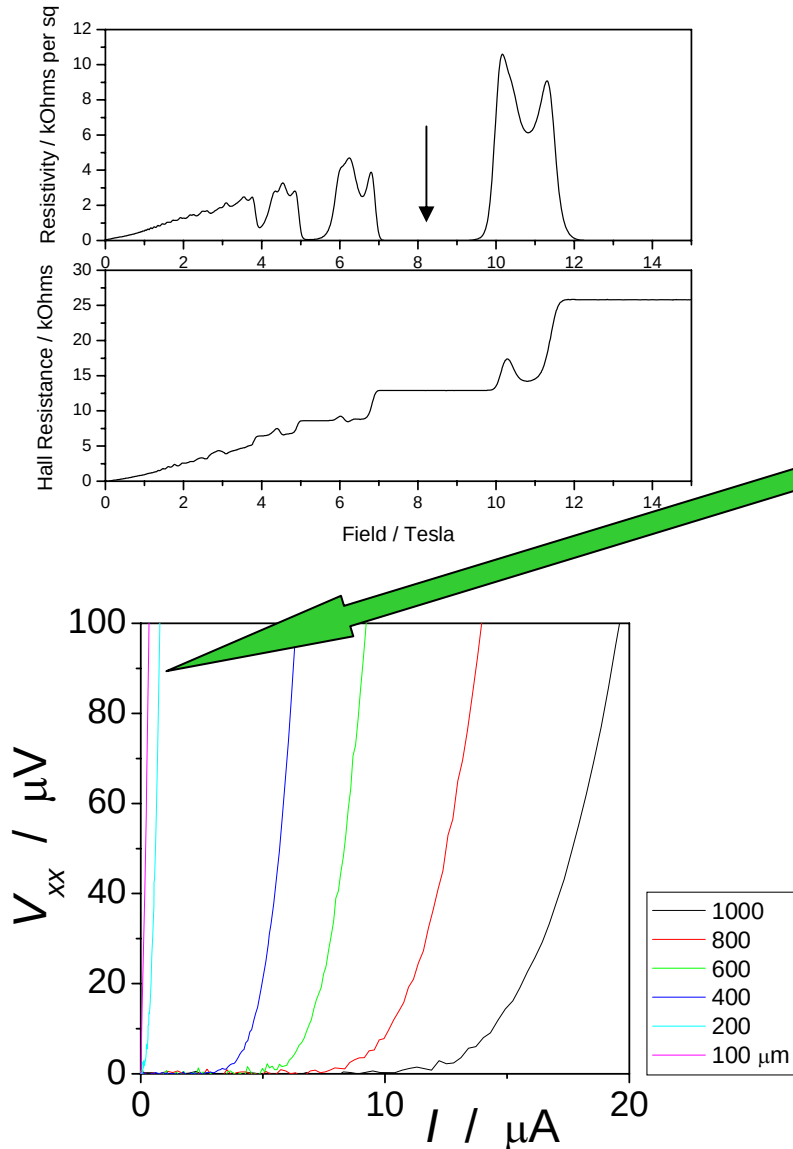
How do $\nu_e - \nu_h = 0$ and $\nu_e - \nu_h \neq 0$ differ?

Current distribution? Are edges important?

- Breakdown (current dependent) behaviour
- Width dependence

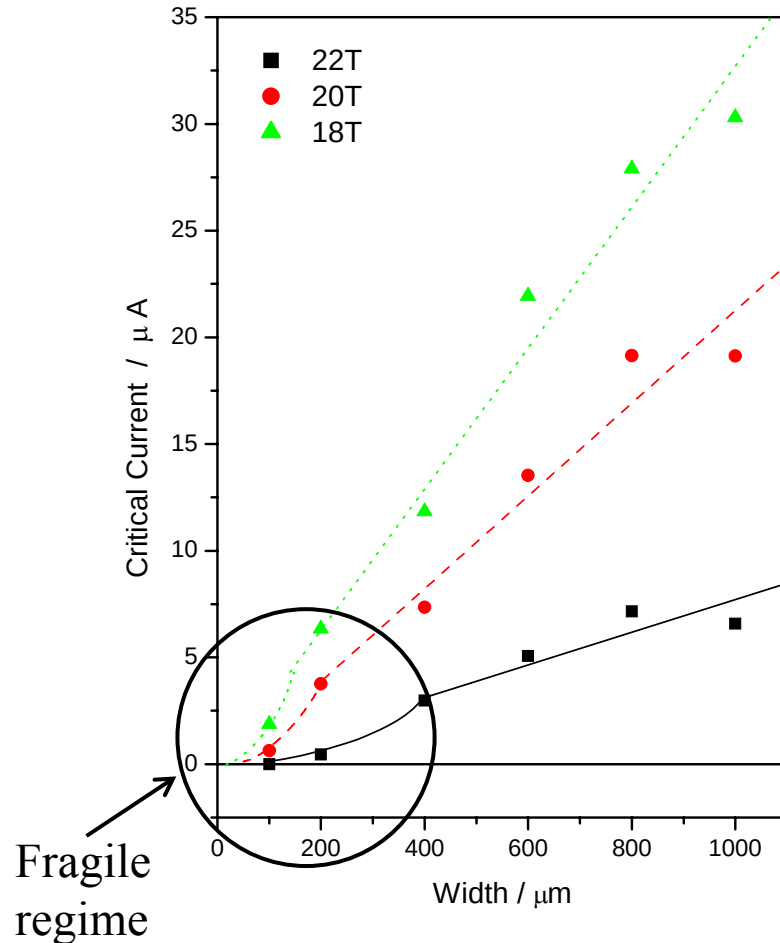
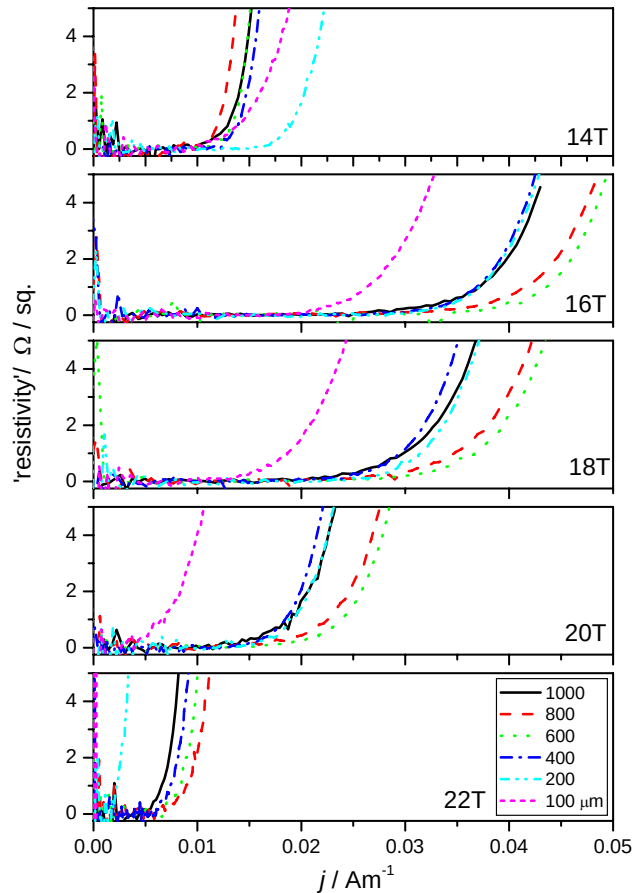
Larger I_c for $n_e:n_h \sim 2:1$

- Compare $\rho_{xx}(j)$
- 'Fragile' regime



Magnetic Field Dependence

- W_c varies systematically with field

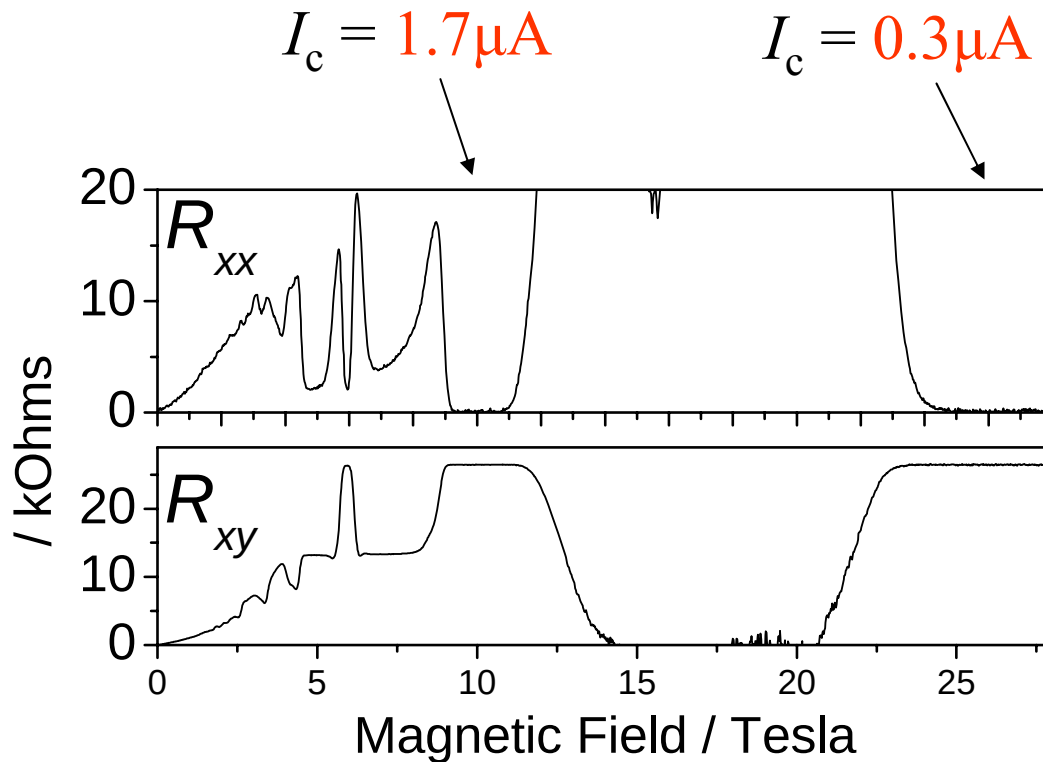
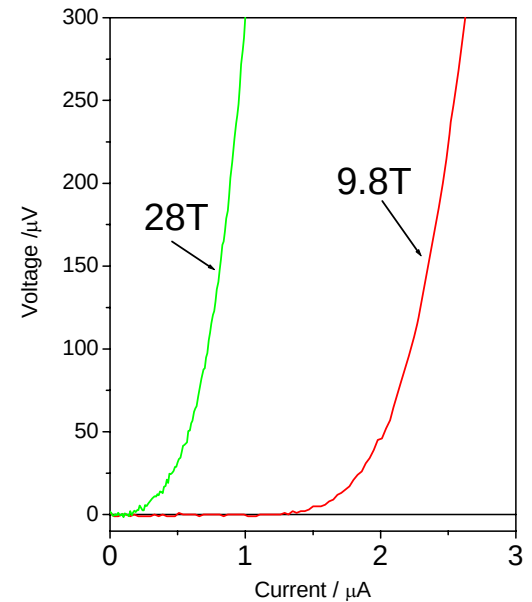


Closely matched $n_e:n_h$

500 μm wide bar, $n_e = 6.3$, $n_h = 4.3 \times 10^{11} \text{cm}^{-2}$

50 mK. Define $I_c = I_c(V_{xx} = 20 \mu\text{V})$

(Rigal et al, PRL 82 (1999) 1249)



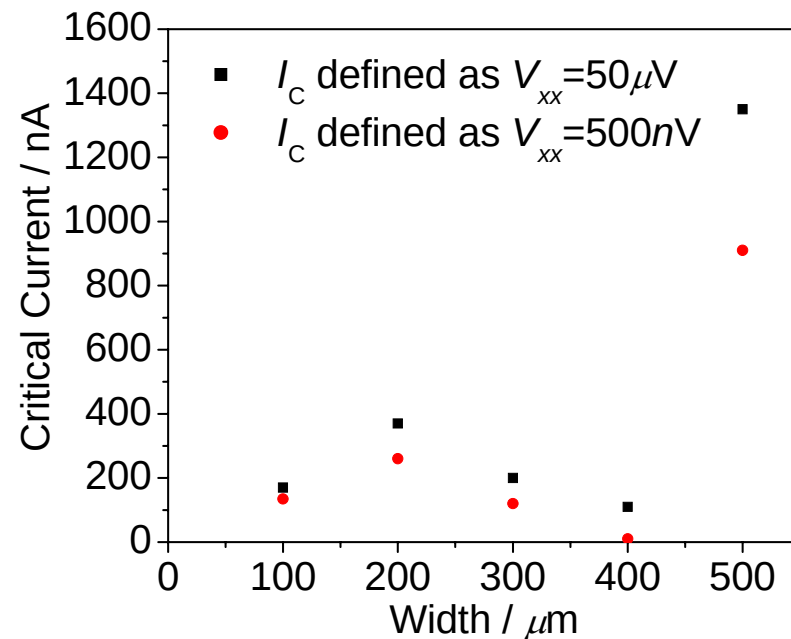
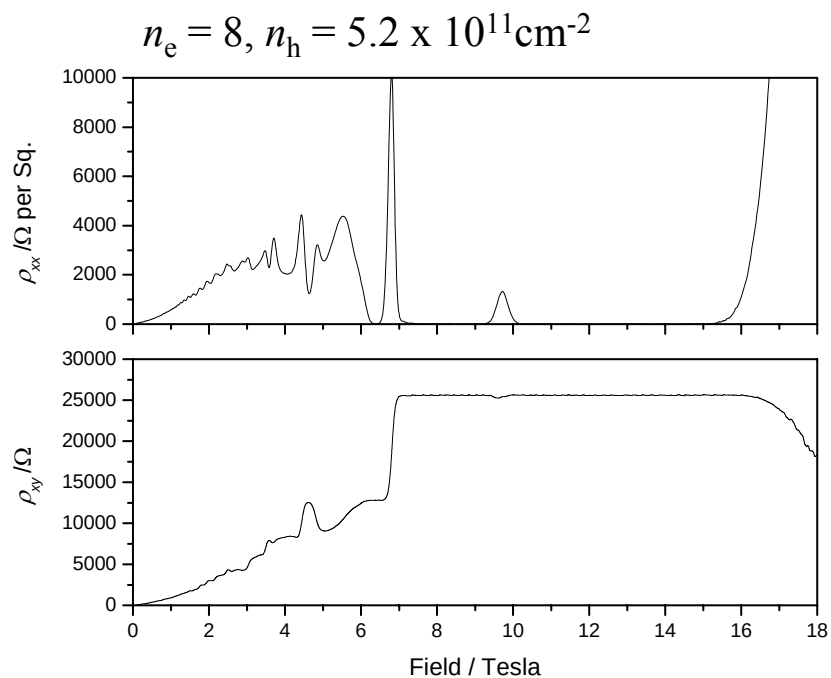
Kawaji et al. J. Phys. Soc. J, 63 (1994) 2303

170 μA , 120 μm n-type
GaAs/(AlGa)As $\nu=2$, 10T

Stoddart et al. Microelectronic Engineering 47
(1999) 35

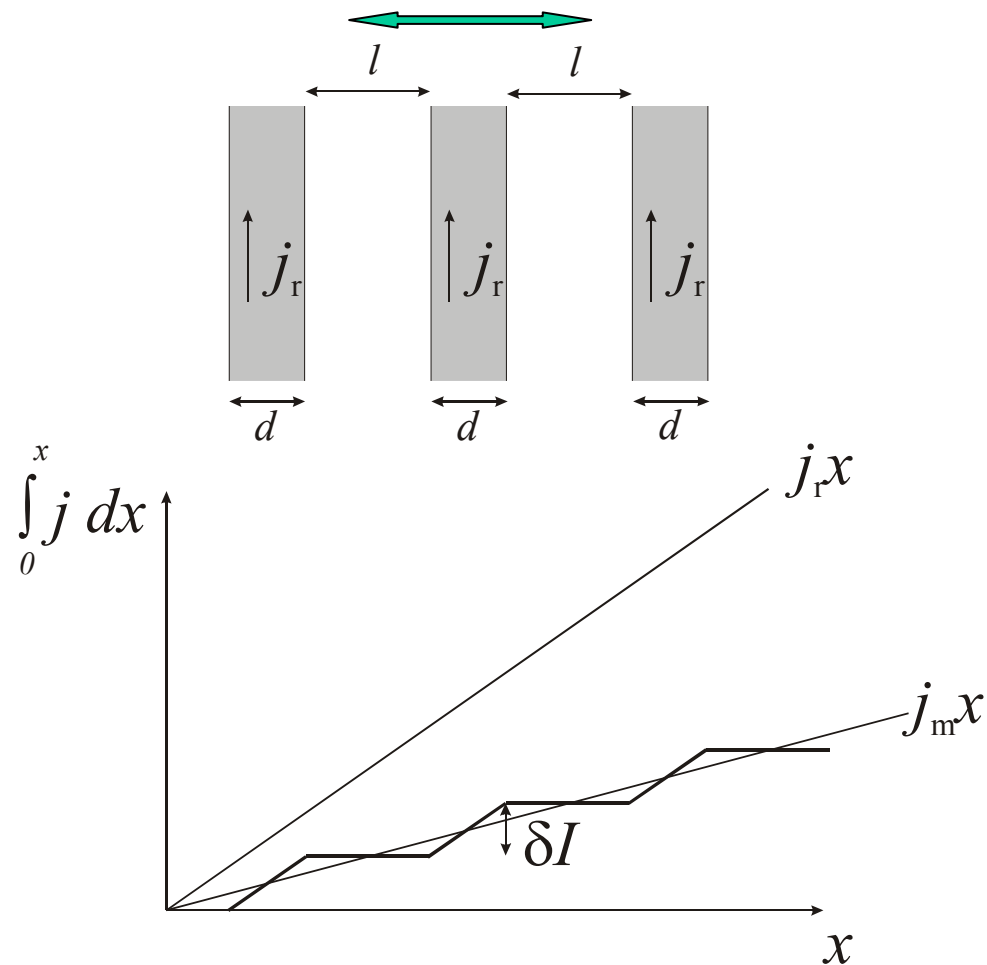
9.2 μA , 200 μm p-type
GaAs/(AlGa)As $\nu=1$, 4.4T

Width Dependence: even 400 μm bar is 'Fragile'!

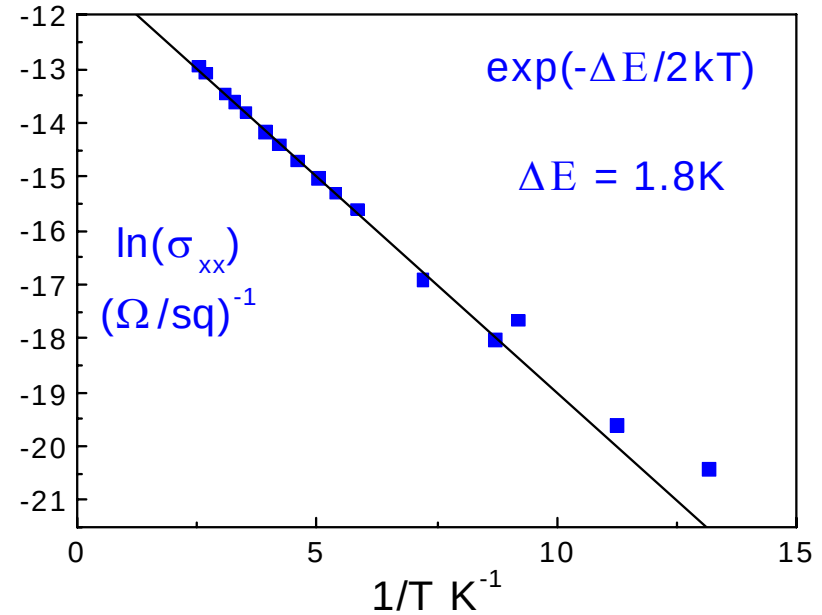
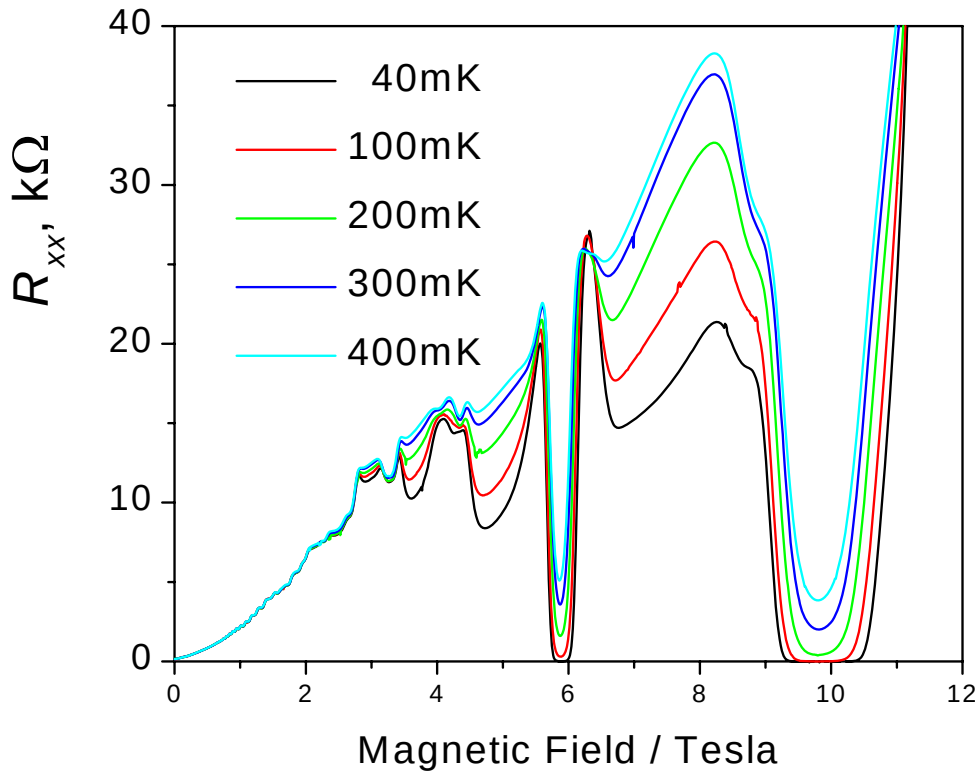


- Small I_c , sensitive to disorder

'Fragile' regime once width is comparable to wide disordered regions: critical width W_c



Compensated Quantum Hall Effect



Conductivity has a very small activation energy

Breakdown Summary

- Ohmic width dependence for wide samples
- Fragile behaviour for 'narrow' samples
- W_c depends on E_F and $E(LL)$ (B dep.)
- Strong influence of disorder when I_c is small

Current flowing in sample interior, inhomogeneous
on a scale W_c .

Summary

$\nu_e - \nu_h = 0$ Insulating States

- $\sigma_{xx} = 0$;
 $\sigma_{xy}^{\text{net}} = \sigma_{xy}^e + \sigma_{xy}^h = 0$
- Current carried by edge-channels, dominating behaviour
- Interior totally insulating

$\nu_e - \nu_h \neq 0$ 'Metallic' States

- $\sigma_{xx} = 0$;
 $\sigma_{xy}^{\text{net}} = \sigma_{xy}^e + \sigma_{xy}^h \neq 0$
- W dependent current dependence
- Current in sample interior